#### **Supporting Information**

# Layered Bi<sub>2</sub>Te<sub>3</sub> Nanoplates/Graphene Composites with High

## Gravimetric and Volumetric Performance for Na-Ion Storage

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### Supporting Data:



**Fig. S1** XRD patterns of pure  $Bi_2Te_3$  and  $Bi_2Te_3/G$  composite.



Fig. S2 TG curve of  $Bi_2Te_3/G$  composite obtained in air atmosphere from room temperature to 800 °C at a rate of 10 °C min<sup>-1</sup>.



Fig. S3 XPS survey spectra of the  $Bi_2Te_3/G$  composite and GNS.



Fig. S4 Raman spectra of GO, GNS, and Bi<sub>2</sub>Te<sub>3</sub>/G composite.



Fig. S5 Cross-section SEM images of (a) fresh Bi<sub>2</sub>Te<sub>3</sub>/G electrode with mass loading of 1.31 mg

and (b) the  $Bi_2Te_3/G$  electrode after 50 cycles at 1 A  $g^{-1}$  with mass loading: 1.43 mg.



**Fig. S6** (a) EIS curves of pure  $Bi_2Te_3$  and  $Bi_2Te_3/G$  composite obtained after two cycles at 1 A g<sup>-1</sup>; and (b) the relationship plots between Z' and  $\omega^{-1/2}$  at low-frequency region of pure  $Bi_2Te_3$  and  $Bi_2Te_3/G$  composite.



**Fig. S7** Equivalent circuit used for fitting of EIS curves (Fig. S5), where  $R_e$  is the electrolyte resistance;  $C_f$  and  $R_f$  are the capacitance and resistance of the surface SEI film formed on the electrodes, respectively;  $C_{dl}$  and  $R_{ct}$  are the double-layer capacitance and charge-transfer resistance, respectively;  $Z_w$  is the Warburg impedance related to the diffusion of Na-ions into the bulk electrodes.

 Table S1 Layered chalcogenide and their corresponding interlayer spacing.

Materials	Interlayer Spacing (Å)	Materials	Interlayer Spacing (Å)	Materials	Interlayer Spacing (Å)
Bi <sub>2</sub> Se <sub>3</sub>	9.56	PdTe <sub>2</sub>	5.13	TiS <sub>2</sub>	5.70
Bi <sub>2</sub> Te <sub>3</sub>	10.16	PtS <sub>2</sub>	5.02	TiSe₂	5.99
CoTe <sub>2</sub>	5.40	PtSe₂	5.06	TiTe <sub>2</sub>	6.51
GaTe₃	5.90	PtTe <sub>2</sub>	5.20	VS <sub>2</sub>	5.73
HfS <sub>2</sub>	5.84	ReS <sub>2</sub>	6.08	WS <sub>2</sub>	6.18
HfSe <sub>2</sub>	6.16	RhTe₂	5.41	WSe <sub>2</sub>	6.49
IrTe <sub>2</sub>	5.39	Si <sub>2</sub> Te <sub>3</sub>	6.74	WTe <sub>2</sub>	7.02
MoS <sub>2</sub>	6.20	SiTe <sub>2</sub>	6.71	ZrS₂	5.81
MoSe <sub>2</sub>	6.50	SnS₂	5.87	ZrSe₂	6.14
MoTe <sub>2</sub>	7.00	SnSe <sub>2</sub>	6.14	ZrSe₃	9.36
NbS <sub>2</sub>	5.96	SnSSe	6.05	ZrTe <sub>2</sub>	6.63
NiTe <sub>2</sub>	5.30	TaS₂	5.86	ZrTe₃	10.01

**Table S2** Electrochemical performance comparison of some advanced metal telluride anode

materials for SIBs.

	Valtage	Initial Caulomhia	Initial dischause (shause	Rate performance				
Materials	range (V)	efficiency (%)	Canacity (mAh/g)	Gravimetric	Volumetric	Current	Cycle life	Ref.
	Tange (V)			capacity (mAh/g)	capacity (mAh/cm <sup>3</sup> )	rate (A/g)		
FeTe <sub>2</sub> -rGO			493/373	421		0.1	80	
				384		0.5		
	0.001-3.0	76		362		1		1
				321		2		
				257		3		
	0.001-3.0	71.9	388/279	343		0.2	200	
				306		0.5		
0014-7-				280		1		2
C@MoTe <sub>2</sub>				254		2		
				236		3		
				209		5		
		62.7	541/339	316	639	0.03		3
				292	600	0.06		
Sata /C	0.001-2.5			272	540	0.16	100	
Shie/C				243	490	0.32	100	
				225	455	0.64		
				213	430	0.96		
	0.005-3.0	37.3	843/314	245.2		0.2	500	4
600 T				127.8		0.5		
C@Cu <sub>1.75</sub> Te				68.1		1		
				44.4		3		
	0.3-2.8	94.1	284.5/267.7	289.5		0.1	5000	5
				281.5		1		
NiTe <sub>2</sub> @NCNs				275.7		2		
				271.6		5		
Bi2Te3	0.3-2.8	79.3	464/368	247.3	910.0	0.1	50	This
				183.5	675.2	0.2		
				98.4	362.1	0.5		
				50.4	185.4	1.0		work
				26.4	97.1	2.0		
				11.7	43.0	5.0		
Bi₂Te₃/G	0.3-2.8	83.5	498/416	312.9	488.1	0.1	500	
				302.9	472.5	0.2		
				275.2	429.3	0.5		This
				252.2	393.4	1.0		work
				229.2	357.6	2.0		
				203.1	316.8	5.0		

**Table S3** Fitting results of the EIS curves for the pure  $Bi_2Te_3$  and  $Bi_2Te_3/G$  composite.

Samples	R <sub>e</sub> (Ω)	R <sub>f</sub> (Ω)	R <sub>ct</sub> (Ω)	σ (Ω rad <sup>1/2</sup> s <sup>-1/2</sup> )	D (cm <sup>2</sup> S <sup>-1</sup> )
Bi <sub>2</sub> Te <sub>3</sub>	14.3	12.5	49.10	93.59	2.36E-18
Bi <sub>2</sub> Te <sub>3</sub> /G	13.21	12.64	18.22	48.07	1.45E-16

# References

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